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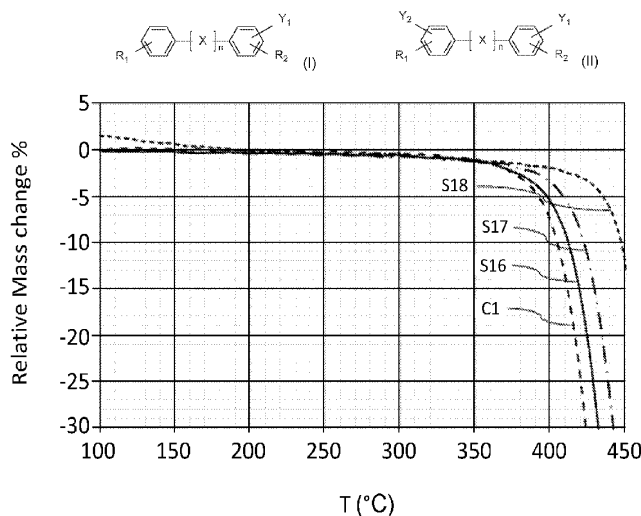


FIG. 1

(57) Abstract: A photocurable composition can comprise a polymerizable material and a photoinitiator, wherein the polymerizable material can comprise a first polymerizable monomer having a structure of Formula (1) or Formula (2), with X being C₁ - C₄-alkyl or oxygen (O); n being 0 or 1; Y₁, Y₂ being or, with R₃ being H or methyl, wherein Y₁ and Y₂ may be the same or different and an amount of Y₁ and Y₂ per benzene ring being 1, 2, or 3; R₁, R₂ being substituted or unsubstituted alkyl or aryl, and an amount of each of R₁ and R₂ per benzene ring being 0, 1, 2, 3, or 4.

[Continued on next page]

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